

# MAGNETIC SENSORS

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## Content:

Hall probes

Magnetoresistances

Electromagnetic induction

## Magnetic field

- Charge generates electric and magnetic fields according to their motion.
  - Still charge → electric field; moving charge → electric field and magnetic field; accelerated charge → electromagnetic field.
- Sensors of magnetic fields are used for direct evaluation of magnetic fields
  - Terrestrial magnetic field (compass), biomagnetism,..
- Or for indirect measurements
  - E.g. position sensors

$$\nabla \cdot \mathbf{E} = \frac{\rho}{\epsilon_0}$$

$$\nabla \cdot \mathbf{B} = 0$$

$$\nabla \times \mathbf{E} = -\frac{\partial \mathbf{B}}{\partial t}$$

$$\nabla \times \mathbf{B} = \mu_0 \mathbf{J} + \mu_0 \epsilon_0 \frac{\partial \mathbf{E}}{\partial t}$$

Magnetic fields sensors are based:

On the interaction with charges in motion (electric current)

Hall effect, magnetoresistors, magnetodiodes, MagFET...

On the interaction with electron spin

Anisotropy Magneto-Resistances, Giant Magneto-Resistance

On the interaction between magnetic fields

Fluxgate magnetometers

## Magnetic field measurement units and typical values

	MKS	CGS
Induced magnetic field B	Tesla [ $V \cdot s \cdot m^{-2}$ ]	Gauss [ $1 T = 10^4 G$ ]
Magnetic field H	Ampere per metro [ $A/m$ ]	Oersted [ $1 Oe = 79 A/m$ ]

$$B = \mu \cdot H$$

$\mu = \mu_r \cdot \mu_0$  magnetic permeability

$$\mu_0 = 4\pi \cdot 10^{-7} \frac{V \cdot s}{m \cdot A}$$

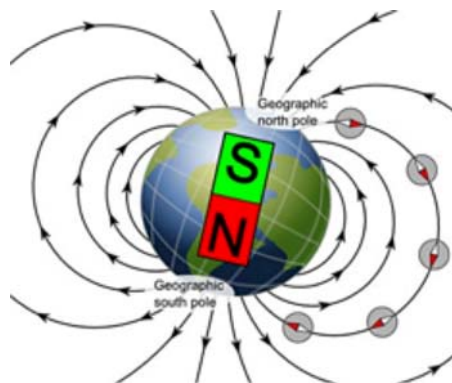
Practical unit: gamma  $1\gamma = 10^{-5} G = 10^{-9} T$

Terrestrial magnetic field	$\approx 0.5 G$
Magnetic field at 1 cm from a conductor carrying a current of 1 A	$\approx 0.2 G$
Heart magnetic field	$\approx 10^{-6} G = 0.1 \gamma$
Brain magnetic field	$\approx 10^{-10} G = 10 \mu\gamma$

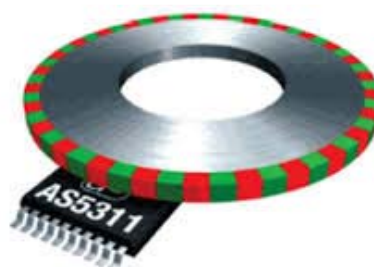
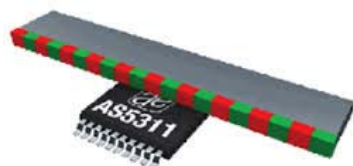
## Main applications

Compass for navigation

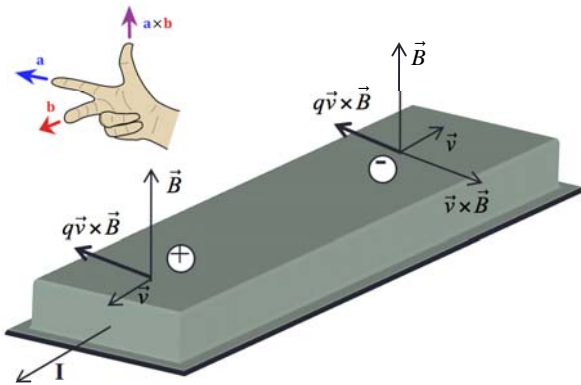
$$B_{\text{earth}} \sim 50 \mu T$$



Position sensors



## Hall effect



In a current-carrying conductor the Lorentz force is balanced by a transversal electric field created by the charges displacement (Hall electric Field).

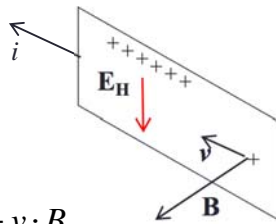
$$\vec{F}_L = q\vec{v} \times \vec{B}; \quad \vec{F}_E = q\vec{E}_H$$

$$q \cdot v \cdot B = q \cdot E_H \Rightarrow E_H = v \cdot B$$

Positive charge carriers

$$\vec{F}_L = +q(+\vec{v}) \times \vec{B}$$

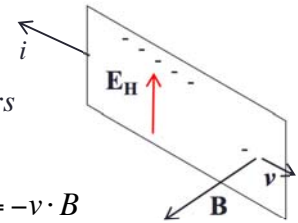
$$q \cdot E_H = q \cdot v \cdot B \Rightarrow E_H = v \cdot B$$



Negative charge carriers

$$\vec{F}_L = -q(-\vec{v}) \times \vec{B}$$

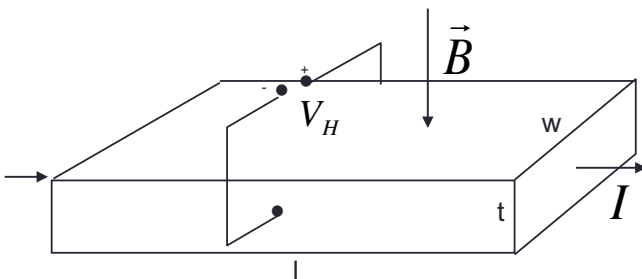
$$-q \cdot E_H = q \cdot v \cdot B \Rightarrow E_H = -v \cdot B$$



The direction of the Hall electric Field depends on the sign of the charge carriers.  
Discrimination between N and P type semiconductors.

## Hall effect based magnetic sensor

- The voltage drop across the section of the conductor is proportional to the magnetic field.



A: cross-section of the conductor  $A = w \cdot t$

n: charge carriers concentration

q: elementary charge

$$I = q \cdot v \cdot n \cdot A \Rightarrow v = \frac{I}{q \cdot n \cdot A} = \frac{I}{q \cdot n \cdot w \cdot t}$$

$$V_H = w \cdot E_H = w \cdot v \cdot B$$

$$V_H = w \cdot \frac{I}{q \cdot n \cdot w \cdot t} \cdot B \Rightarrow V_H = \frac{I}{q \cdot n \cdot t} \cdot B$$

$$\text{Hall coefficient: } R_H = \frac{1}{qn} = \frac{V_H \cdot t}{I \cdot B}$$

Sensitivity is inversely proportional to the carriers concentration and to the thickness of the conductor.  
The largest sensitivity is achieved by semiconductor thin films.

## Hall effect in metals and semiconductors

- Numerical examples

- metal  $t = 0.2 \text{ mm}$

$$n = 8.5 \times 10^{28} \text{ m}^{-3}$$

$$I = 1 \text{ A}$$

$$S_H = \frac{I}{q \cdot n \cdot t} = \frac{1}{1.6 \times 10^{-19} \cdot 8.5 \times 10^{28} \cdot 2 \times 10^{-4}} = 0.37 \frac{\mu\text{V}}{\text{T}}$$

- Doped semiconductor  $t = 0.2 \text{ mm}$

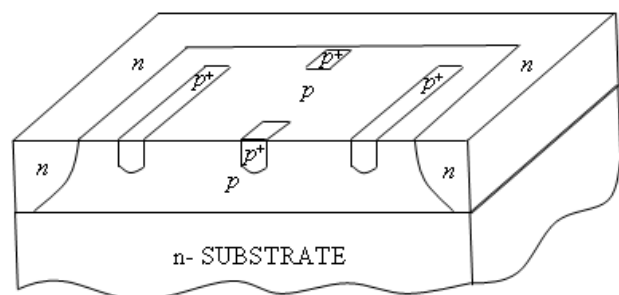
$$n = 1 \times 10^{20} \text{ m}^{-3}$$

$$I = 10 \text{ mA}$$

$$S_H = \frac{I}{q \cdot n \cdot t} = \frac{10^{-2}}{1.6 \times 10^{-19} \cdot 1 \times 10^{21} \cdot 2 \times 10^{-4}} = 0.31 \frac{\text{V}}{\text{T}}$$

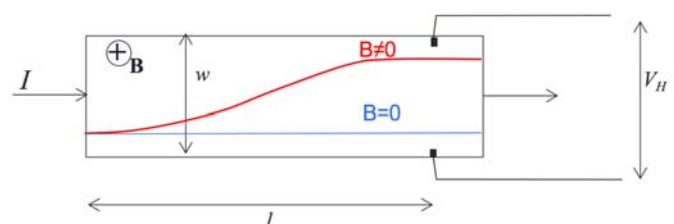
## Hall probe

- The hall probe is a thin semiconductor with four orthogonal contacts.
- It can be fabricated either as a thin film on an insulating substrate or as an implanted layer on a semiconductor wafer.
- Doping is light because the sensitivity is inversely proportional to the carriers concentrations
- Most used materials are InSb, InAs, GaAs, Si, and Ge. Composite semiconductors are characterized by a large mobility, but silicon is preferred for integrated sensors.
- Typical sensitivities are of the order of 100 V/A\*T but up to 1000 V/A\*T can be achieved.
- Resolution can be of the order of 10 mG.



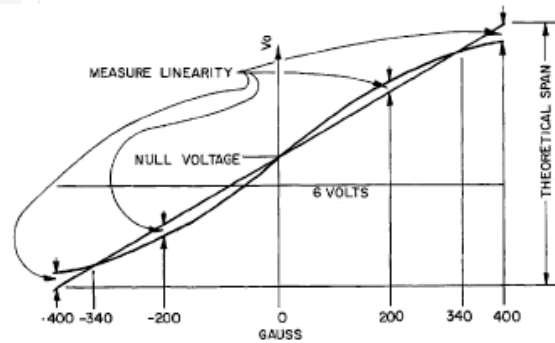
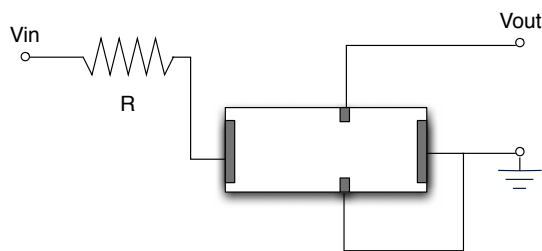
### Size effect.

- If  $l$  is too short, the charges reach the electrode with a small deflection and then the electric field is not in equilibrium with the Lorentz force.
- To consider this effect a geometrical factor is introduced ( $G < 1$ ) proportional to  $l/w$ . In practice,  $G = 1$  when  $l > 3w$ .



# Honeywell 91SS12

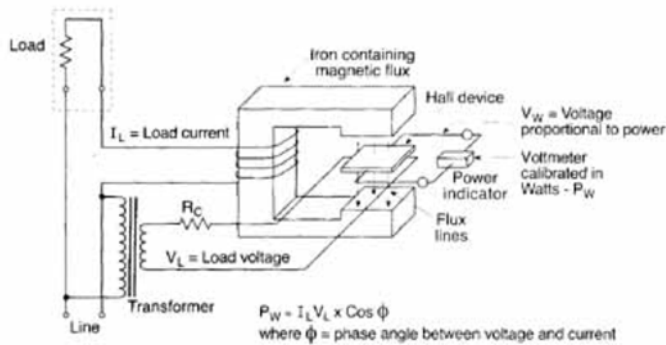
Product Specifications	
Product Type	Hall-Effect Linear Position Sensor
Package Type	Ceramic SIP
Supply Voltage	8.0 Vdc to 16.0 Vdc
Output Type	Source
Termination Type	PC Board
Magnetic Actuation Type	Ratiometric Linear
Operating Temperature	-40 °C to 150 °C [-40 °F to 302 °F]
Output Voltage	6.0 Vdc ± 0.6 Vdc @ 12 Vdc
Linearity (% of Span)	±1.5% max.
Temperature Error	± 0.05% (Null Shift)
Availability	Global
Supply Current	19 mA
Output Current (max.)	10 mA
Sensitivity	7.5 mV ± 0.2 mV/G
Response Time	3 ms (typ.)
Series Name	91SS
Magnetic Range	-40 mT to 40 mT [-400 G to 400 G] min.
Output Voltage Span	6.0 Vdc @ 12 Vdc (typ.)



## Wattmeter with a Hall sensor

- Hall sensors can enable the product of currents and voltages.
- For instance, Hall sensors can be used to measure the power of a a.c. signal

$P=V \cdot I$        $V_L$  provides the current to the sensor and  $I_L$  generates the magnetic field



$$B = \mu \cdot N_S \cdot I_L$$

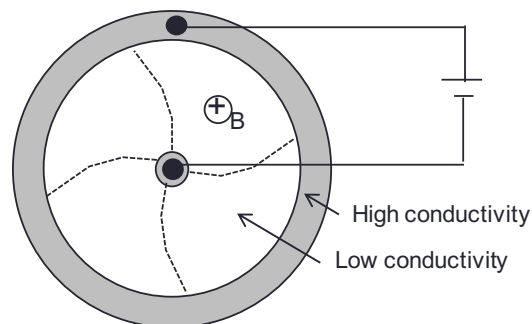
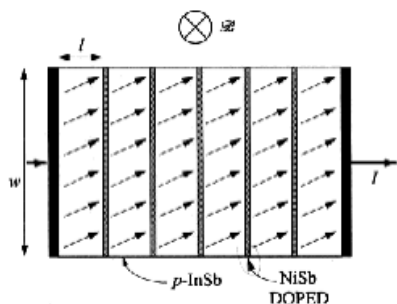
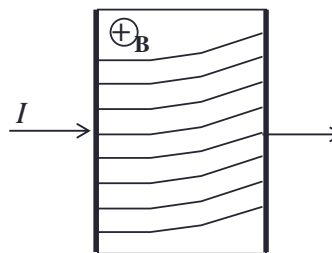
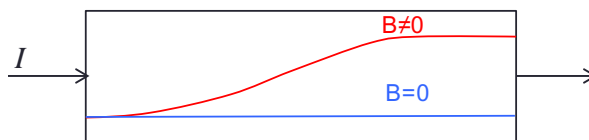
$$I_H = \frac{V_L}{R_C + R_S}$$

$$V_H = S_H \cdot I_H \cdot B = S_H \cdot \frac{V_L}{R_C + R_S} \cdot \mu \cdot N_S \cdot I_L = K \cdot P$$

$$K = S_H \cdot \frac{\mu \cdot N_S}{R_C + R_S}$$

# Magnetoresistance

- Electric resistance is proportional to the path travelled by the charges.
- The magnetic field deflects the trajectories of the charges and then it increases the electric resistance.
- The effect is more intense if the Lorentz force is not equilibrated by the Hall electric field. This happens in conductors where the length is almost 3 times smaller than the width ( $l < 3w$ ).
- To maximize the effects subtle layers of conductors are sandwiched between metallic conductors.



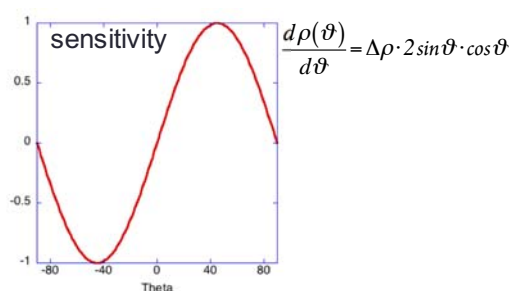
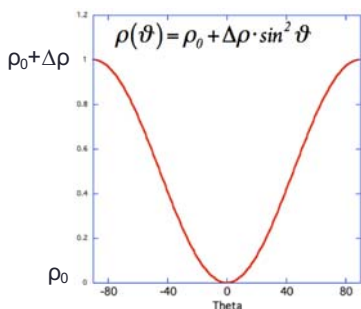
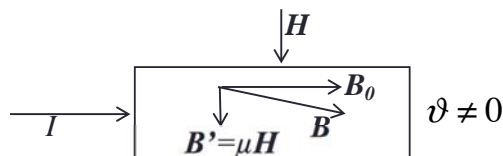
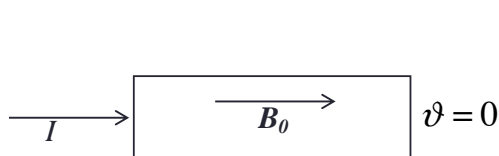
Corbino disk: the circular structure avoids the formation of the Hall electric field.

# Interaction with electronic spin Anisotropic MagnetoResistance (AMR)

- In ferromagnetic materials the probability of charge scattering, and then the resistivity, is a function of the angle between the current vector ( $\mathbf{J}$ ) and the magnetic field ( $\mathbf{B}$ ).

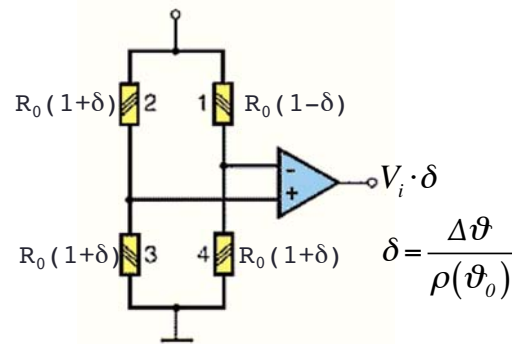
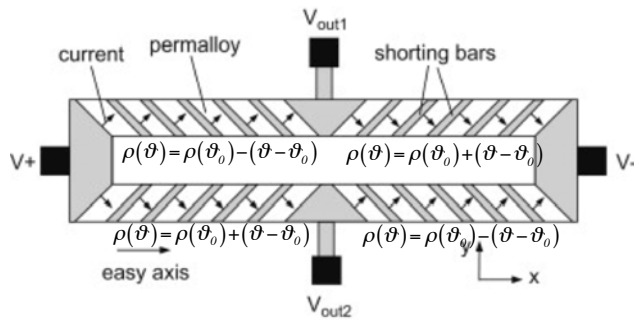
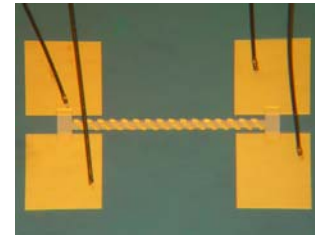
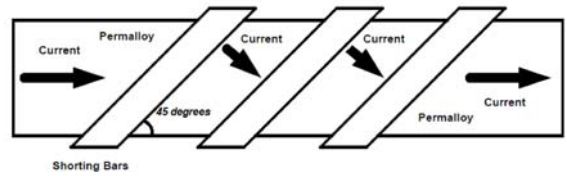
$$\rho(\vartheta) = \rho_0 + \Delta\rho \cdot \sin^2 \vartheta$$

- The AMR is formed by a thin film with a ordered magnetization vector ( $\mathbf{B}_0$ ).
- The internal magnetic field sums with an external magnetic field. This results in a change of the resistance.  $\Delta\rho$  is of the order of 1%.



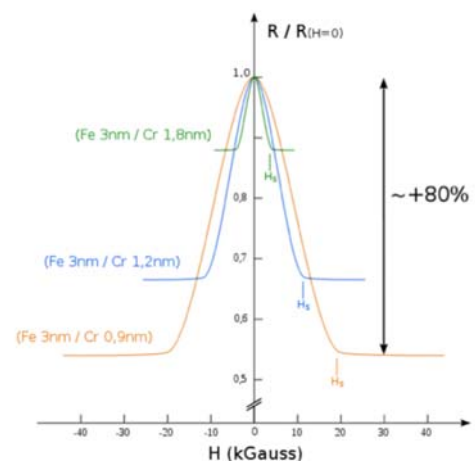
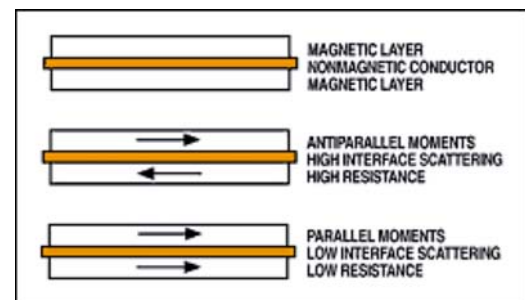
## Barber pole AMR

- The sensitivity is maximum when the current direction is  $\pm 45^\circ$  with respect to the magnetization direction.
  - Permalloy (80% Ni, 20% Fe) ferromagnetic material.
  - Metallic shorting bar redirects the current at  $45^\circ$  C.
- Changing the direction of the shorting bars the sign of the sensitivity is changed. So a sensor with positive and negative sensitivities can be designed.
- This feature is exploited in a full Wheatstone bridge.



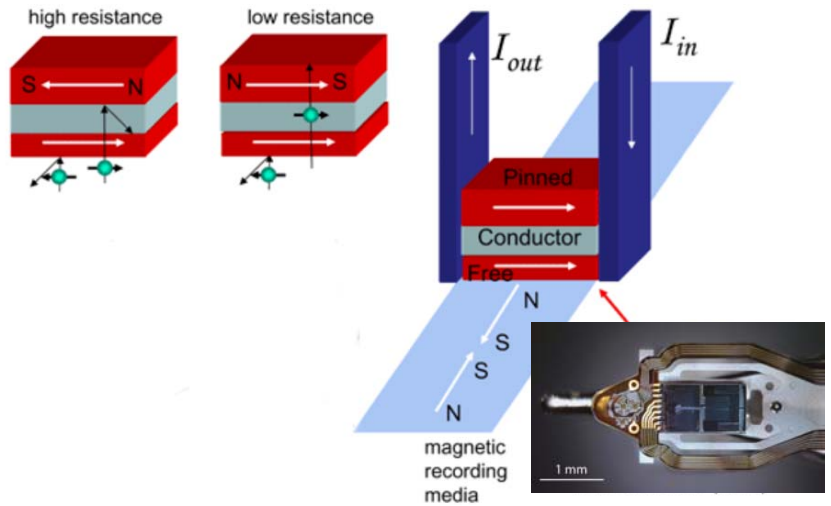
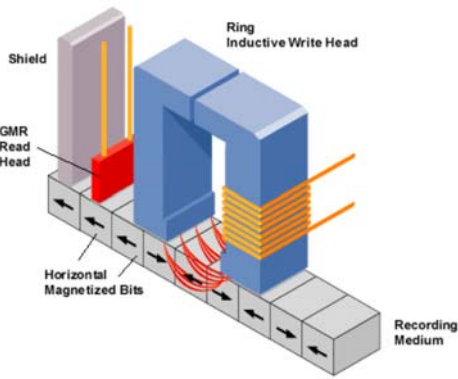
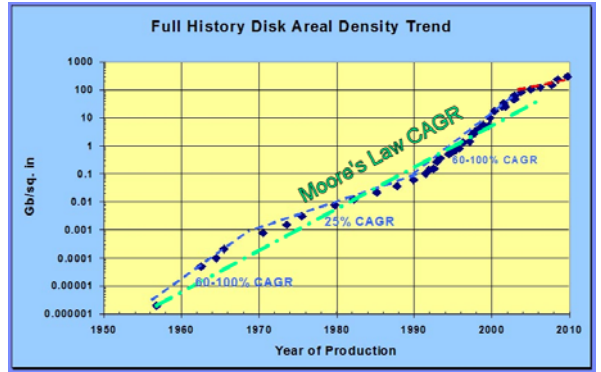
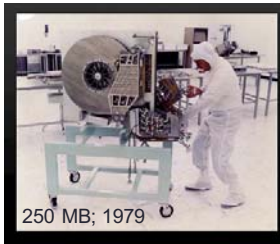
## Giant MagnetoResistance (GMR)

- It is observed in structures formed by two ferromagnetic materials separated by a ultrathin ( $<1\text{nm}$ ) non magnetic layer.
- The electric resistance strongly depends on the magnetic dipoles orientation of the two ferromagnetic materials.
- The application of an external magnetic field to one of the ferromagnetic switches the magnetic moment changing the resistance.



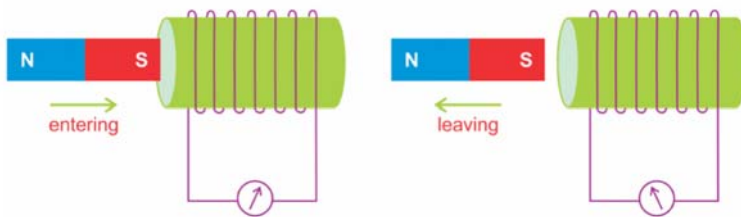
# Hard disks

- GMR allows for the miniaturization of magnetic sensors. For instance, for the compression of bit area in hard disks.



# Electromagnetic induction

A variable magnetic fields induces a current in a coil

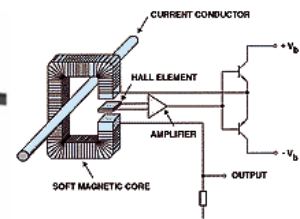
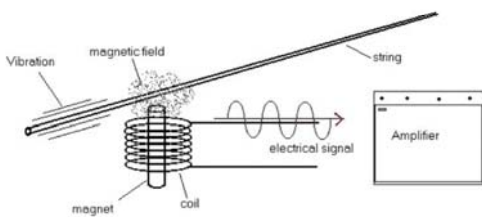


$$\Delta V = - \frac{d\Phi_B}{dt}$$

$$\Phi_B = \int_{\Sigma} B \cdot dl$$

Current (a.c.) clamp  
Variable B is generated by a a.c. current

$$B(r) = \frac{\mu_0 I}{2\pi r}$$



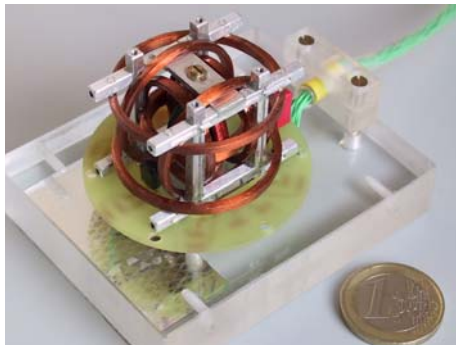
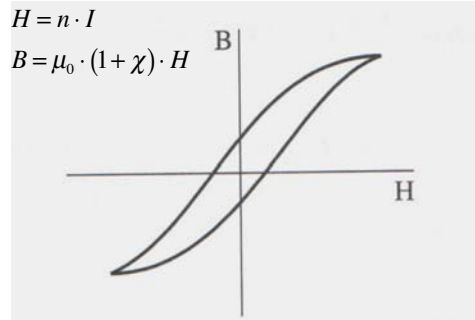


## Fluxgate magnetometer

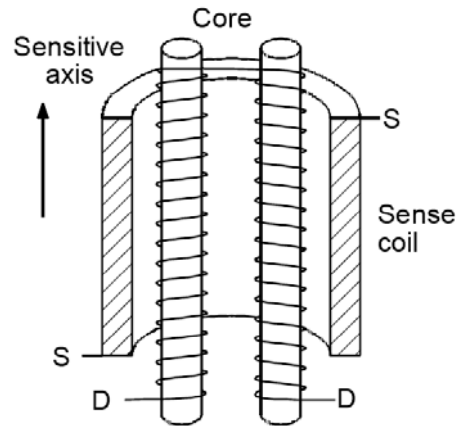
- Two core coils oppositely folded are surrounded by a larger single coil (Sense coil).
- The current applied to the core coils induces two opposite fields that cancel each other.
- In presence of an external magnetic field, the equilibrium is broken and the net magnetic field inside the larger coil induces a current in the sense coil.
- Fluxgates achieves resolutions of the order of  $10^{-5}$  G (100 times better than Hall sensors).

$$H = n \cdot I$$

$$B = \mu_0 \cdot (1 + \chi) \cdot H$$



3 axis magnetometer



## Fields, fluxes and voltages

For sake of simplicity, let us suppose a linear hysteresis

